## Supplementary information for:

# Grafting metal complexes onto amorphous supports: from elementary steps to catalyst site populations via kernel regression

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	TABLE OF CONTENTS	Page
Section S1	Parameters in model of grafting barriers and lattice displacements	S2
Section S1.1	Grafting temperature and dimensionless precursor concentration (m)	<b>S</b> 2
Section S1.2	DFT computational details	<b>S</b> 2
Fig. S1	The optimized bis(silanolato)chromium(II) cluster	S2
Section S1.3	Morse potential parameters	<b>S</b> 3
Fig. S2	Calculation of the M-O bond strength	<b>S</b> 3
Fig. S3	Calculation of the M <sup>…</sup> O bond strength	<b>S</b> 4
Section S1.4	Lattice displacements	S5
Section S1.5	$\varepsilon_{\text{HL}}$ , $V_*$ , $\Delta PV$ , and $\Delta S^{\circ}$ to compute grafting free energy	S5
Section S1.6	Reference free energy barrier and linear free energy relation ( $\Delta G^{\dagger}_{ref}$ )	<b>S</b> 5
Fig. S4	Calculation of the reference free energy barrier	<b>S</b> 6
Section S2	Effect of training set size on test set error	<b>S</b> 7
Fig. S5	Residual distributions for predicted grafting barriers as a function of	<b>S</b> 7
	training set size for all ~ 20,000 sites	
Section S3	Optimized Cartesian coordinates	<b>S</b> 8
Section S4	Additional references	S9

## S1. Parameters in model of grafting barriers and lattice displacements

#### S1.1. Grafting temperature and dimensionless precursor concentration (*m*)

The grafting temperature was chosen to be 298.15 K (room temperature). The ratio of the ML<sub>2</sub> concentration in the gas phase to the reference concentration  $(\hat{V}_0^{-1})$ ,  $m = [\mathbf{ML}_2]/\hat{V}_0^{-1}$ , was set to the ratio of CrO<sub>2</sub>Cl<sub>2</sub> vapor pressure at 298.15 K (20 Torr) to atmospheric pressure (760 Torr), giving m = 0.026.

#### S1.2. DFT computational details

 $D_{M-O}$ ,  $D_{M-O}$ ,  $a_{M-O}$ ,  $a_{M-O}$ ,  $a_{M-O}$ , and  $\Delta G^{\dagger}_{ref}$  were set using density functional theory (DFT) calculations. All DFT calculations were performed with the  $\omega$ B97X-D functional.<sup>1</sup> The def-2TZVP basis set<sup>2</sup> was used for chromium and the TZVP basis set<sup>3, 4</sup> was used for all other atoms. The Berny algorithm, as implemented in Gaussian 16, was used to find minima and transition states.<sup>5</sup> The RMS and maximum forces were required to be less than  $3.00 \times 10^{-4}$  Hartrees/Bohr and  $4.50 \times 10^{-4}$  Hartrees/Bohr, respectively, while the RMS and maximum displacements were required to be less than  $1.20 \times 10^{-3}$  Bohr and  $1.80 \times 10^{-3}$  Bohr respectively. Transition states were required to have one imaginary frequency.

To make a reference site for DFT calculations, the bis(silanolato)chromium(II) cluster was optimized and its peripheral atom positions were held fixed for all subsequent computations to mimic a rigid support, Fig. S1.



**Fig. S1** The optimized bis(silanolato)chromium(II) cluster. Color scheme: oxygen (red), hydrogen (white), silicon (blue), and chromium (purple). Peripheral atoms (fixed) are transparent.<sup>6</sup>

#### S.1.3. Morse potential parameters

The M-O bond strength ( $D_{M-O}$ ) was calculated by removing the Cr atom from the bis(silanolato) chromium(II) and performing a single-point energy calculation, Fig. S2.  $D_{M-O}$  was calculated using

$$D_{\mathbf{M}-O} = E_{II} + E_{Cr} - E_{I}.$$
 (S1)

Here  $E_{II}$  is the electronic energy of structure II,  $E_{Cr}$  is the electronic energy of a Cr atom, and  $E_I$  is the electronic energy of the bis(silanolato)chromium(II) cluster (structure I). We get  $D_{M-O} = 524.4$  kJ/mol.



**Fig. S2** Calculation of the M-O bond strength. Electronic energies of the optimized Cr(II) cluster (left) and cluster with dissociated Cr (right). Peripheral atoms (fixed) are red.  $d_1$  is used as the displacement variable in a Morse potential model (below).

The Morse potential width (*a*) can be related to the force constant by a second-order Taylor expansion of V(r) around the equilibrium bond length  $(r_{eq})$ :

$$V(r) \approx \frac{d^2 V}{dr^2} \frac{\left(r - r_{eq}\right)^2}{2!} = k \frac{\left(r - r_{eq}\right)^2}{2} = Da^2 \left(r - r_{eq}\right)^2.$$
 (S2)

Here, *k* is the force consant. The zeroth-order term of the taylor expansion evaluates to 0 by construction, while the first derivative evaluates to 0 because  $r_{eq}$  corresponds to the minimum of the potential energy surface. Thus,  $a = [k/2D]^{1/2}$ . The force constant was computed using DFT by calculating the second derivative of the potential energy with respect to the Cr-O bond length (*d*<sub>1</sub>). We obtain  $k_{M-O} = 0.2063$  Ha/Bohr and  $a_{M-O} = 1$ . Here  $a_{M-O}$  was non-dimensionalized by  $d_1$ .

The non-dimensionalized equilibrium bond distance for the M-O bond  $(r_{M-O,eq})$  was set to 1.

To calculate the M<sup> $\dots$ </sup>O bond strength ( $D_{M \dots O}$ ), a water molecule was adsorbed on the bare Cr cluster, and the cluster was reoptimized while keeping the positions of the peripheral atoms fixed, Fig. S3. The bond strength of the Cr $\cdots$ OH<sub>2</sub> bond was calculated using

$$D_{\mathbf{M}\dots 0} = E_I + E_{H_0} - E_{III}.$$
 (S3)

Here  $E_I$  is the electronic energy of structure I,  $E_{H_2O}$  is the electronic energy of the optimized water molecule, and  $E_{III}$  is the electronic energy of structure III. We get  $D_{M...O} = 117$  kJ/mol.



**Fig. S3** Calculation of the M····O bond strength. Electronic energies of the Cr cluster with H<sub>2</sub>O adsorbed (left) and the bare Cr cluster and H<sub>2</sub>O in the gas phase (right). Peripheral atoms (fixed) are red.  $d_2/d_3$  was used to compute  $r_{\mathbf{M}...O,eq}$  and  $d_3$  was used as a displacement variable in the Morse potential model for M···O.

 $k_{\mathbf{M}...o}$  was computed as the second derivative of the energy of structure III with respect to the Cr...O bond length ( $d_3$ ). We get  $k_{\mathbf{M}...o} = 0.054$  Ha/Bohr and  $a_{\mathbf{M}...o} = 2.3$  (Eq. (S2)). Here  $a_{\mathbf{M}...o}$  was non-dimensionalized by  $d_3$  (Fig. S3).

The non-dimensionalized equilibrium M<sup>···</sup>O bond length ( $r_{M...o,eq}$ ) was set to  $d_3/d_2$ . This yields  $r_{M...o,eq} = 1.16$ .

#### **S1.4.** Lattice displacements

The lattice points were displaced by drawing displacements according to a bivariate Gaussian distribution using the numpy.random.multivariate\_normal function in python:<sup>7</sup>

$$p(\boldsymbol{x},\boldsymbol{\mu},\boldsymbol{\Sigma}) = \frac{1}{2\pi |\boldsymbol{\Sigma}|^{\frac{1}{2}}} exp\left(-\frac{1}{2}(\boldsymbol{x}-\boldsymbol{\mu})^{T} \boldsymbol{\Sigma}^{-1}(\boldsymbol{x}-\boldsymbol{\mu})\right).$$
(S4)

Here  $\Sigma$  is a 2x2 dimensional covariance matrix,  $\mu \in \mathbf{R}^2$  is the mean, and  $\mathbf{x} \in \mathbf{R}^2$  is a 2D random variable representing displacement of lattice points. The covariance matrix was set equal to a scalar diagonal matrix

$$\Sigma = \sigma_{lattice}^2 I. \tag{S5}$$

Here *I* is the 2x2 identity matrix. The value of  $\sigma^2_{lattice}$  was set to 0.00022 and the value of  $\mu$  was set to (0,0).

#### S1.5. $\varepsilon_{\rm HL}$ , $V_*$ , $\Delta PV$ , and $\Delta S^{\circ}$ to compute grafting free energy

From Eq. (4), it follows that the grafting energy for a site on the unperturbed lattice is given by

$$\Delta E_{unperturbed} = 2\varepsilon_{\mathbf{HL}} - (V_* + 2\varepsilon_{\mathbf{ML}}) + V_{\mathbf{M}^*} \left( \mathbf{x}_{unperturbed} \right).$$
(S6)

Here  $V_{M^*}$  is obtained by optimizing the metal position in a site on an unpertubed lattice. Similarly, from Eq. (8) it follows that the grafting free energy on an unperturbed site is given by

$$\Delta G_{unperturbed}^{\circ} = 2\varepsilon_{\mathbf{HL}} - (V_* + 2\varepsilon_{\mathbf{ML}}) + V_{\mathbf{M}^*} \left( \mathbf{x}_{unperturbed} \right) + \Delta \mathbf{PV} - T\Delta S^{\circ}.$$
(S7)

Rearranging Eq. (S7), we get

$$2\varepsilon_{\mathbf{HL}} - (V_* + 2\varepsilon_{\mathbf{ML}}) + \Delta \mathbf{PV} - T\Delta S^{\circ} = \Delta G_{unperturbed}^{\circ} - V_{\mathbf{M}^*} \left( \mathbf{x}_{unperturbed} \right).$$
(S8)

Using Morse potential parameters from Section 1.3, we obtain  $V_{\mathbf{M}*}(\mathbf{x}_{unperturbed}) = -1259.57 \text{ kJ/mol}$ . To make grafting favorable for a reference site,  $\Delta G^{\circ}_{unperturbed}$  was set equal to -30 kJ/mol. This yields  $2\varepsilon_{\mathbf{HL}} - (V_* + 2\varepsilon_{\mathbf{ML}}) + \Delta PV - T\Delta S^{\circ} = 1229.56 \text{ kJ/mol}$ .  $\varepsilon_{\mathbf{HL}}$ ,  $V_*$ ,  $\varepsilon_{\mathbf{ML}}$ ,  $\Delta PV$ , and  $\Delta S^{\circ}$  always occur together in the combination on the LHS of Eq. (S8), therefore they do not need to be determined separately.

#### S1.6. Reference free energy barrier and linear free energy relation ( $\Delta G^{\dagger}_{ref}$ )

The LFER for an unperturbed site is given by

$$\Delta G_{unperturbed}^{\ddagger}\left(\mathbf{r}\right) = \Delta G_{ref}^{\ddagger} + \alpha \Delta G_{unperturbed}^{\circ}\left(\mathbf{r}\right).$$
(S9)

 $\Delta G^{\dagger}_{unperturbed}(\mathbf{r})$  was set equal to the DFT-computed activation barrier for CrO<sub>2</sub>Cl<sub>2</sub> grafting to a vicinal disilanol model site at 1 atm pressure of CrO<sub>2</sub>Cl<sub>2</sub> (Fig. S4).



**Fig. S4** Calculation of the reference free energy barrier. Free energies of  $CrO_2Cl_2$  in the gas phase with the vicinal silanol site (left) and the transition state for  $CrO_2Cl_2$  grafting to the vicinal silanol site (right). Free energies are at 1 atm  $CrO_2Cl_2$  and 298.15 K. Peripheral atoms (fixed) are red.

Using  $\Delta G^{\circ}_{unperturbed} = -30 \text{ kJ/mol}$  (Section 1.5) and solving for  $\Delta G^{\dagger}_{ref}$  we get

$$\Delta G_{ref}^{\ddagger} = 131.3 kJ / mol. \tag{S10}$$

## S2. Effect of training set size on test set error

100 sites were chosen for training because it is the minimum training set size with a test set error < 0.5 kJ/mol.  $2\sigma < 1$  kJ/mol implies a 95 % confidence in predictions within chemical accuracy (1kJ/mol). Figure S5.



**Fig. S5** Residual distributions for predicted grafting barriers as a function of training set size for all  $\sim$  20,000 sites. As expected, the width of the residual distribution decreases on increasing the training set size.

## S3. Optimized Cartesian coordinates

				Si	0.326075	2.970978	0.018794
Ι				Н	1.148930	6.972860	2.668851
0	1,528811	1.824313	-0.017388	0	1.081087	6.020796	2.752306
0	0.329378	3.677175	-1.481621	н	1.518486	5.602420	1.984661
0	-3.798259	2.422246	0.623913	Н	2.801681	-1.777950	-1.369223
0	-2.438002	0.962699	2.368112	H <sub>2</sub> O			
H	1.471909	1.112917	0.626314	Н	-4.608746	5.621161	3.576918
Н	0.721158	3.163281	-2.193268	0	-4.583973	5.230285	4.450516
Н	-3.813749	2.949384	-0.179589	Н	-4.630806	5.969246	5.057441
Н	-3.058546	0.287885	2.079326	CrC	2 <b>C1</b> 2		
Cr	-0.581114	4.653929	2.451205	Cr	-0.813596	0.931968	-0.026679
0	0.574657	4.129092	1.143994	0	-1.929832	1.847660	-0.541532
0	-2.075437	3.611653	2.410588	0	0.532336	1.454304	-0.541523
0	-1.118168	2.236282	0.338845	C1	-1.126960	-1.029644	-0.761437
Si	-2.359099	2.327446	1.438932	C1	-0.808773	0.962166	2.091171
Si	0.334619	2.972583	0.013179	IV			
II				0	1.528811	1.824313	-0.017388
0	-1.479020	1.063597	-0.171917	0	0.329378	3.677175	-1.481621
0	1.479919	1.062495	0.169382	0	-3.798259	2.422246	0.623913
0	-0.000064	-1.152570	-0.010169	0	-2.438002	0.962699	2.368112
Si	1.549993	-0.562218	0.019959	Н	1.471909	1.112917	0.626314
Si	-1.549694	-0.561184	-0.022650	Н	0.721158	3.163281	-2.193268
0	-2.373190	-1.327126	-1.234709	Н	-3.813749	2.949384	-0.179589
0	-2.338964	-0.932841	1.376401	Н	-3.058546	0.287885	2.079326
0	2.357723	-1.330005	1.241761	0	0.452818	4.100190	1.148729
0	2.354669	-0.932487	-1.370478	0	-2.079978	3.617865	2.397352
Н	-1.862034	-1.546446	-2.012360	0	-1.125250	2.209046	0.338162
Н	-2.799779	-1.770818	1.373882	Si	-2.366906	2.321508	1.441114
Н	1.832745	-1.558780	2.007440	Si	0.297459	2.926241	-0.015455
Н	2.801681	-1.777950	-1.369223	Н	1.131843	4.762355	1.026301
III				Н	-1.227754	4.046968	2.262093
0	1.528715	1.824430	-0.017273	V			
0	0.329040	3.677023	-1.481622	0	1.528811	1.824313	-0.017388
0	-3.798037	2.422373	0.623959	0	0.329378	3.677175	-1.481621
0	-2.437772	0.962573	2.367903	0	-3.798259	2.422246	0.623913
Н	1.471874	1.112840	0.626215	0	-2.438002	0.962699	2.368112
Н	0.721382	3.163392	-2.193211	Н	1.471909	1.112917	0.626314
Н	-3.813726	2.949265	-0.179675	Н	0.721158	3.163281	-2.193268
Н	-3.058776	0.288005	2.079504	Н	-3.813749	2.949384	-0.179589
Cr	-0.583821	4.714397	2.500341	Н	-3.058546	0.287885	2.079326
0	0.579509	4.129526	1.136052	0	0.532837	4.159347	1.128393
0	-2.065920	3.613509	2.402040	0	-2.188510	3.614718	2.443646
0	-1.121537	2.226881	0.331971	0	-1.098231	2.277343	0.398604
Si	-2.356280	2.335183	1.444016	Si	-2.367921	2.298347	1.428234

Si	0.342124	2.973369	0.006307	Cl -3	.077539	6.049800	2.962288
Cr	-1.133593	4.244207	3.873462	Cl 0	.122137	2.506696	4.047915
0	-0.168197	5.426249	3.758314	H -2	.839503	4.669098	2.418243
0	-1.837495	4.321604	5.228652	H 1	.181758	4.843077	0.968990

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